

Accelerating Low-temperature Processing of Printed Nanoinks Using Machine Learning and Bayesian Optimization of Non-thermal Plasma Jet Sintering

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Motivation

- Rapid processing of emerging nanomaterials on flexible and thermosensitive substrates for applications in wearable electronics and in *situ* sensors
- Non-thermal plasma jets enable simple and lowtemperature sintering of printed thin films on delicate substrates^{1,2}
- Machine learning Bayesian optimization (BO) approaches optimize multidimensional experimental problems in a low-cost and efficient way³

References

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Optimization Workflow & Results



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Objectives:

- ➢ maximize electrical conductivity (σ) of
- ITO thin films
- > minimize the peak substrate temperature (T_{max})
- Decision variables: $Q, \overline{U, f, d, n, t_{on}}, \overline{t_{off}}$
- BO increases SEI by $2.4 \times$
- Pareto front indicates the best trade-off between σ and T_{max}

Acknowledgements

This work was supported by the United States Department of Energy under Award Number DE-EE0009103.

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Summary

- Bayesian optimization method optimized 7-dimensional variable space to maximize the electrical conductivity of ITO films and control the substrate temperature under a relatively low value
- Non-thermal plasma jet sintering of ITO produced a conductivity of 7.6 S m⁻¹ with a substrate temperature below 47 °C in 1 hour
- Achieved 81.4% of furnace sintering with a temperature 250 °C lower and 3× faster

